

L Number	Hits	Search Text	DB	Time stamp
1	0	t-butyl adj acrylic adj acid <i>East Search</i>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/23 12:51
-	257	octafluorocyclopentene hexafluorocyclobutene	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/23 12:51
-	17	decafluorocyclohexene	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 10:52
-	260	(octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 10:52
-	30	((octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene) and (photoresist resist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:08
-	2586	\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:08
-	412107	(photoresist resist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:08
-	16849	(photoacid acid) near generat\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:09
-	1027638	solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:09
-	10	(\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and (photoresist resist)) and ((photoacid acid) near generat\$4) and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:16
-	6	(US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.	USPAT; US-PGPUB	2003/09/22 11:10
-	7	(((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and (photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:10
-	3	(((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and (photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and (photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:19

-	244	LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:23
-	2	(LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO) and (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) (octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene) cycloolefin same (fluoro fluorinated fluorine)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:42
-	109		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:43
-	32	(perfluoro near ring)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:56
-	2	jp-2001122928-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:50
-	4	((("6403744") or ("20030157432")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:49
-	1	wo-200290423-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:49
-	8	jp-2001330955-\$.did. jp-2001122928-\$.did. (((("6403744") or ("20030157432")).PN.) wo-200290423-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:50
-	0	6403744.URPN.	USPAT	2003/09/22 11:53
-	6	("3418302" "3449304" "5637663" "5663255" "6133389" "6156824").PN.	USPAT	2003/09/22 11:53
-	141	(cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:56
-	9	((cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:56
-	9	((((cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4)) and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:07
-	0	polyhexafluorocyclobutene/2-methyl adj 2-adamantyl adj 5-norbornene-2-carboxylate	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:08
-	0	polyhexafluorocyclobutene	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:08
-	0	polyhexafluorocyclobutane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:08

-	0	polyoctafluorocyclopent?ne	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:08
-	1	poly adj octafluorocyclopent?ne	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:08
-	1	poly adj hexafluorocyclobut?ne	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:09
-	1	poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:10
-	5368	cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
-	3626	((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:12
-	66	(cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
-	65	((cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (((((cycloolefin same (fluoro fluorinated fluorine)) (perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.) ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19

65	(((cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (((((cycloolefin same (fluoro fluorinated fluorine)) (perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.) (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO))) not (jp-2001330955-\$ did. jp-2001122928-\$ did. ((("6403744") or ("20030157432")).PN.) wo-200290423-\$ did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:20
1609	cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
10	(cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
10	((cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (((((cycloolefin same (fluoro fluorinated fluorine)) (perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.) (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
10	((cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (jp-2001330955-\$ did. jp-2001122928-\$ did. ((("6403744") or ("20030157432")).PN.) wo-200290423-\$ did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:20
7	((("5547558") or ("4566755") or ("4732941") or ("4500694") or ("4742140") or ("4609715") or ("4569871")).PN. jp-2001330955-\$ did.	USPAT	2003/09/22 14:13
2		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 15:04